Subdiass CLASSIFICATION	
U.S. UTILITY Patent Application	
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APPLICATION NO. CONT/PRIOR CLASS SUBCLASS ART.UNIT EXAMINER 09/817197 F 43934 00/.3 1746 MARKOFF	
Naoya Hayamizu	
Washing method, method of manufacturing semiconductor device and method of manufacturing active matrix-type display device	
BEST AVAILABLE COPY	
ISSUING CLASSIFICATION	
ORIGINAL CROSS REFERENCE(S)	
CLASS SUBCLASS CLASS SUBCLASS (ONE SUBCLASS PER BLOCK)	
INTERNATIONAL CLASSIFICATION	15.
Continued on Issue Slip Inside File Jacket	1
TERMINAL DRAWINGS CLAIMS ALLOWED	
DISCLAIMER Sheets Drwg. Figs. Drwg. Print Fig. Total Claims Print Claim to	or O.G.
NOTICE OF ALLOWANCE MAII	LED
The term of this patent subsequent to (date) has been disclaimed. (Assistant Examiner) (Date)	
The term of this patent shall not extend beyond the expiration date	
of U.S Patent. No Amount Due Date Pa	id
(Primary Examiner) (Oate) ISSUE BATCH NUMBER	
The terminalmonths of this patent have been disclaimed. (Legal Instruments Examiner) (Date)	
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